Reg. No. :

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B.E./B.Tech. DEGREE EXAMINATION, NOVEMBER/DECEMBER 2016.

Sixth Semester

Electronics and Communication Engineering

EC 2354/EC 64 - VLSI DESIGN

(Regulations 2008)

(Common to PTEC 2354 – VLSI Design for B.E. (Part-Time) Fifth Semester – Electronics and Communication Engineering – Regulations 2009)

Time : Three hours

Maximum : 100 marks

Answer ALL questions.

PART A — $(10 \times 2 = 20 \text{ marks})$

- 1. List the various issues in Technology-CAD.
- 2. Define the lambda layout rules.
- 3. Give the effect of supply voltage and temperature variations on the CMOS system performance.
- 4. What are the factors that cause static power dissipation in CMOS circuits?
- 5. Implement a 2:1 Multiplexer using pass transistor.
- 6. Design a 1-bit dynamic register using pass transistor.
- 7. What is a Tester, Test Fixture and Handler?
- 8. Mention the different types of CMOS testing techniques.
- 9. What are procedural assignments in Verilog?
- 10. What is a switch level modeling?

PART B — $(5 \times 16 = 80 \text{ marks})$

- 11. (a)
- (i) Explain the different steps involved in n-well CMOS fabrication process with neat diagrams. (10)
- (ii) Draw the CMOS inverter and discuss its DC characteristics. Write the conditions for the different regions of operation.

Or

- (b)(i) An NMOS transistor has a nominal threshold voltage of 0.16 V. Determine the shift in threshold voltage caused by body effect using the following data. The nMOS transistor is operating at a temperature of 300°K with the following parameters : gate oxide thickness $(t_{OX}) = 0.2 \times 10^{-5}$ cm, relative permittivity of gate oxide $(\varepsilon_{OX}) = 3.9$, relative permittivity of silicon $(\varepsilon_{Si}) = 11.7$, substrate bias voltage = 2.5 V, intrinsic electron concentration $(N_{\rm c}) = 1.5 \times 10^{10} / {\rm cm}^3$, impurity concentration in substrate $(N_A) = 3 \times 10^{16} / \text{cm}^3$. Given Boltzmann's constant = $1.38 \times 10^{-23} \text{ J/}^{\circ}\text{K}$, electron charge = 1.6×10^{-19} Coulomb and permittivity of free space $= 8.85 \times 10^{-14}$ F/cm. (8)
 - (ii) Explain the principle of SOI technology with neat diagrams. Discuss its advantages and disadvantages.
 (8)
- 12. (a) Derive an expression for the rise time, fall time and propagation delay of a CMOS inverter.

Or

- (b) Explain the various ways to minimize the static and dynamic power dissipation.
- 13. (a
- (a) Explain in detail about the pipeline concepts used in sequential circuits.

(16)

(8)

(8)

Or

- (b) Discuss the design techniques to reduce switching activity in a static and dynamic CMOS circuits, (16)
- 14. (a) (i) List the manufacturing test principles and explain them. (8)
 - (ii) Explain Built-in Self-Test.

Or

- (b) (i) Discuss on the Test Logic Architecture and Test Access Port. (8)
 - (ii) Explain on the scan design strategy of testing.

- 15. (a) Explain the following in VERILOG with an suitable example :
 - (i) Timing controls and Conditional statements
 - (ii) Behavioural and Gate level modelling.
 - Or
 - (b) Write the VERILOG code for
 - (i) Priority Encoder
 - (ii) Equality Detector.

(16)

(16)